

<b>Search Notes</b> 	Application/Control No.	Applicant(s)/Patent under Reexamination
	10/706,755	KIM ET AL.
	Examiner	Art Unit
	Stephen W. Smoot	2813

S.W.S.

SEARCH NOTES (INCLUDING SEARCH STRATEGY)		
	DATE	EXMR
Key Words: Isolation - Shallow Trench, STI, Field Oxide, FOX;	2/25/2005	S.W.S. SWS
Buried Insulator - Oxide, BOX, Silicon-on-Insulator, SOI; Epitaxial Layer - Silicon.	2/25/2005	S.W.S. SWS
Search Tools - EAST (attached): USPAT; US PG PUBS; Derwent; EPO; JPO; IBM TDB	2/25/2005	S.W.S. SWS